

Laser : a tool for material processing at nanometer scale.

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Rapid development of fast and ultrafast lasers has opened a wide variety of new and exciting applications and possibilities for 2D and 3D high precision material processing. During the two last decades, lasers have demonstrated their ability of micro-machining and micro-structuring almost any material by direct ablative processing, self nanostructuring and also to produce nanoclusters with a control size distribution. This result together with the reductions in cost and complexity of laser systems have peaked interest in short and ultrashort laser ablation for synthesis of materials with highly ordered structures at the nanometer scale with unusual physical properties that allow their use as nanoscale devices in microelectronics, optics, biochemistry, etc. In the present report different laser processes to produce nanostructures such as laser ablation in liquids (fig. 1), self structuring (fig.2 and 3), nanocluster and particle-assisted laser near field enhancement (fig. 4) will be presented.

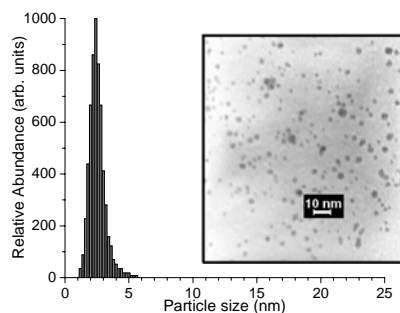


Fig 1: Colloidal Au nanoparticles produced by fs laser ablation in aqueous solutions^[1].

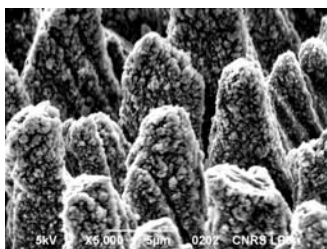


Fig 2 : laser surface self nanostructuring of silicon ($\lambda = 800$ ns, pulse duration 100 fs)^[2].

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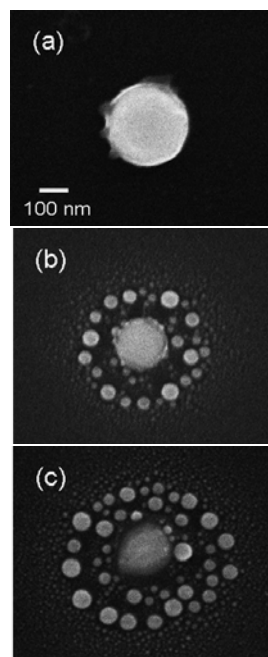


Fig. 3. SEM images of a 125 nm radius Au particles deposited on Si substrates and irradiated by single laser pulses ($\lambda = 193$ nm) with different laser fluences: (a) 200 $mJ\ cm^{-2}$, (b) 280 $mJ\ cm^{-2}$ and (c) 350 $mJ\ cm^{-2}$ ^[3].

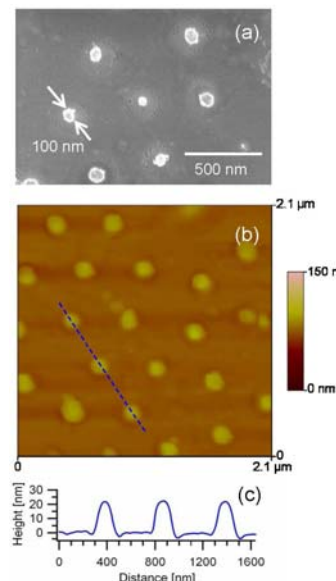


Fig. 4: (color online) SEM image (a), AFM image (b) and depth profile (c) of gold nanodots created on silicon substrates by the LF-PAM based process^[4]

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- [4] A. Pereira et al., *Small* **4** (5), 572-576, (2008).